

Material data sheet

EOS NickelAlloy HX

EOS NickelAlloy HX is a heat and corrosion resistant metal alloy powder intended for processing on EOS M 290 systems.

This document provides information and data for parts built using EOS NickelAlloy HX powder (EOS art.-no. 9011-0023) on the following system specifications:

• EOS M 290 400W with EOSPRINT 1.x and EOS Parameter set HX Performance 2.0

Description, application

EOS NickelAlloy HX raw material is a nickel-chromium-iron-molybdenum alloy in fine powder form. Its composition corresponds to UNS N06002. While the wrought and cast versions of the alloy generally are solution annealed, the laser melted material manufactured of this powder has a high strength and good elongation already in the as-built condition. Solution annealing of the laser sintered material will homogenize the microstructure, relax internal stresses and increase the elongation, while slightly decreasing the strength.

This type of alloy is characterized by having high strength and oxidation resistance also at elevated temperatures, and is often used up to 1200°C. Therefore its applications can be found in aerospace technology, gas turbine parts, etc.

Standard laser processing parameters results in full melting of the entire geometry, typically with 40 μ m layer thickness. Parts built from EOS NickelAlloy HX can be heat treated and material properties can be varied within specified range. In both as-built and solution heat treated states the parts can be machined, spark-eroded, welded, micro shot-peened, polished, and coated if required. Unexposed powder can be reused.

EOS GmbH - Electro Optical Systems



Technical data*

General process data

	EOS NickelAlloy HX
Typical achievable part accuracy [1]	
- small parts	approx. ±50-80 μm (± 0.0020 – 0.0031 inch)
- large parts	approx. \pm 0.2 %
Min. wall thickness [2]	typ. 0.4 - 0.5 mm (0.016 – 0.020 inch)
Layer thickness	40 μm
Surface roughness [3]	
- after shot-peening (horizontal / vertical)	R_a 3 $-$ 6.5 μ m, R_z 10 $-$ 30 μ m R_a 0.12 $-$ 0.25 x 10 $^{-3}$ inch, R_z 0.39 $-$ 1.18 x 10 $^{-3}$ inch
- after polishing	R_z up to $< 0.5~\mu m$ R_z up to $< 0.02~x~10^{-3}$ inch (can be very finely polished)
Volume rate [4]	4.2 mm³/s (15.2 cm³/h) 0.93 in³/h

- [1] Based on users' experience of dimensional accuracy for typical geometries, e.g. \pm 50 μ m when parameters can be optimized for a certain class of parts or \pm 80 μ m when building a new kind of geometry for the first time. Part accuracy is subject to appropriate data preparation and postprocessing.
- [2] Mechanical stability is dependent on geometry (wall height etc.) and application
- [3] Due to the layerwise building, the surface structure depends strongly on the orientation of the surface, for example sloping and curved surfaces exhibit a stair-step effect. The values also depend on the measurement method used. The values quoted here given an indication of what can be expected for horizontal (up-facing) or vertical surfaces.
- [4] Volume rate is a measure of build speed during laser exposure. The total build speed depends on the average volume rate, the recoating time (related to the number of layers) and other factors such as DMLS-Start settings.



Physical and chemical properties of parts*

	EOS NickelAlloy HX		
Material composition	Element	Min	Max
	Ni	bal	ance
	Cr	20.5	23.0
	Fe	17.0	20.0
	Mo	8.0	10.0
	W	0.2	1.0
	Co	0.5	2.4
	С		0.1
	Si		1.0
	Mn		1.0
	S		0.03
	Р		0.04
	В		0.01
	Se		0.0050
	Cu		0.5
	Al		0.5
	Ti		0.15
Relative density with standard parameters	aį	prox. 100	%
Density with standard parameters	min. 8.2 g/cm3 min. 0.296 lb/in ³		



Mechanical properties of parts (at room temperature)*

As built
typ. 820 ± 50 MPa
typ. 675 <u>±</u> 50 MPa
typ. 630 ±50 MPa
typ. 545 <u>±</u> 50 MPa
typ. 195 ±20 GPa
typ. 175 <u>±</u> 20 GPa
typ. 27 ±8 %
typ. 39 ±8 %

^[5] Tensile testing according to ISO 6892-1:2009 (B) Annex D, proportional test pieces, diameter of the neck area 5 mm (0.2 inch), original gauge length 25 mm (1 inch).

Abbreviations

typ. typical min. minimum approx. approximately wt weight



*Part properties are provided for information purposes only and EOS makes no representation or warranty, and disclaims any liability, with respect to actual part properties achieved. Part properties are dependent on a variety of influencing factors and therefore, actual part properties achieved by the user may deviate from the information stated herein. This document does not on its own represent a sufficient basis for any part design, neither does it provide any agreement or guarantee about the specific properties of a material or part or the suitability of a material or a part for a specific application.

This powder has not been developed, tested or certified as a medical device according to Directive 93/42/EEC (MDD) or Regulation (EU) 2017/745 (MDR) and is not intended to be used as a medical device, in particular for the purposes specified in Art. 2 No. 1 MDR. Insofar as you intend to use the powder as raw material for the manufacture of pharmaceutical products or medical devices (e.g. as raw material which as a material must meet the requirements of Annex 1, Chapter II MDR), the responsibility and liability for all analyses, tests, evaluations, procedures, risk assessments, conformity assessments, approval and certification procedures as well as for all other official and regulatory measures required for this purpose shall lie solely with you both with regard to the pharmaceutical product and/or medical device manufactured by you and with regard to the properties, suitability, testing, evaluation, risk assessment, other requirements for use of the powder as raw material.

This also applies to applications with food contact. In this respect, the limitations of liability pursuant to our General Terms and Conditions and the system sales or material contracts shall apply.

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EOS NickelAlloy HX

EOS NickelAlloy HX is a nickel metal alloy powder intended for processing on EOS DMLS systems.

This document provides information and data for parts built using EOS NickelAlloy HX powder (EOS art.-no. 9011-0023) on the following specifications:

- EOS DMLS system M400-4
- EOSYSTEM: EOSPRINT v.1.5/HCS v.2.4.14
- EOS Parameter set HX FlexLine 40μm

Description

EOS NickelAlloy HX is a nickel-chromium-iron-molybdenum alloy in fine powder form. Its composition corresponds to UNS N06002. While the wrought and cast versions of the alloy generally are solution annealed, the laser sintered version has a high strength and good elongation already in the as-built condition. Solution annealing of the laser sintered material will homogenize the microstructure, relax internal stresses and increase the elongation, while slightly decreasing the strength.

This type of alloy is characterized by having high strength and oxidation resistance also at elevated temperatures, and is often used up to 1200°C. Therefore its applications can be found in aerospace technology, gas turbine parts, etc.

Parts built from EOS NickelAlloy HX can be heat treated and material properties can be varied within specified range. In both as-built and solution heat treated states the parts can be machined, spark-eroded, welded, micro shot-peened, polished, and coated if required. Unexposed powder can be reused.

Robert-Stirling-Ring 1



Technical Data

Powder properties

The chemical composition of the powder is reported in the table below.

Material composition	Element	Min	Max
	Ni	Balance	
	Cr	20.5	23.0
	Fe	17.0	20.0
	Мо	8.0	10.0
	W	0.2	1.0
	Со	0.5	2.4
	С	-	0.1
	Si	-	1.0
	Mn	_	1.0
	S	_	0.03
	P	_	0.04
	В	-	0.01
	Se	_	0.0050
	Cu	-	0.5
	Al	-	0.5
	Ti	-	0.15
Max. particle size			
Particles > 63μm [1]	max. 0.5 wt.	0/0	

^[1] Sieve analysis according to ASTM B214.

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General process data

Layer thickness	40 μm
Volume rate [2]	16.8 mm ³ /s (60.8 cm ³ /h)

^[2] The volume rate is a measure of build speed during laser exposure of the skin area. The total build speed depends on this volume rate and many other factors such as exposure parameters of contours, supports, up and downskin, recoating time, Home-In or LPM settings.

Physical and chemical properties of parts*

Part density [3]	min. 8.2 g/ cm ³
Surface roughness after shot peening [4]	Ra 4-6.5 μm; Rz 20-50 μm

^[3] Weighing in air and water according to ISO 3369.

Tensile data at room temperature* [5, 6]

	As built	Heat treated [7]
Ultimate tensile strength, Rm	770 MPa	710 MPa
Yield strength, Rp0.2	610 MPa	345 MPa
Elongation at break, A	31 %	45 %

- [5] The numbers are average values and are determined from samples with horizontal and vertical orientation.
- [6] Tensile testing according to ISO 6892-1 B10, proportional test pieces, diameter of the neck area 5 mm (0.2 inch), original gauge length 25 mm (1 inch).
- [7] Heat treatment procedure: According to AMS2773 and AMS5390: Solution anneal at 1177°C for 1 hour, followed by rapid air cooling to below 60°C.

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Robert-Stirling-Ring 1

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^[4] Measurement according to ISO 4287. The numbers were measured at the horizontal (up-facing) and all vertical surfaces of test cubes. Due to the layerwise building the roughness strongly depends on the orientation of the surface, for example sloping and curved surfaces exhibit a stair-step effect.



Abbreviations

min. minimum max. maximum wt. weight

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This powder has not been developed, tested or certified as a medical device according to Directive 93/42/EEC (MDD) or Regulation (EU) 2017/745 (MDR) and is not intended to be used as a medical device, in particular for the purposes specified in Art. 2 No. 1 MDR. Insofar as you intend to use the powder as raw material for the manufacture of pharmaceutical products or medical devices (e.g. as raw material which as a material must meet the requirements of Annex 1, Chapter II MDR), the responsibility and liability for all analyses, tests, evaluations, procedures, risk assessments, conformity assessments, approval and certification procedures as well as for all other official and regulatory measures required for this purpose shall lie solely with you both with regard to the pharmaceutical product and/or medical device manufactured by you and with regard to the properties, suitability, testing, evaluation, risk assessment, other requirements for use of the powder as raw material. This also applies to applications with food contact. In this respect, the limitations of liability pursuant to our General Terms and Conditions and the system sales or material contracts shall apply.

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